

10/72 8,210, 8/13/05, *RPA*,**WEST Search History**

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DATE: Saturday, August 13, 2005

Hide?	Set Name	Query	Hit Count
	<i>DB=PGPB; PLUR=YES; OP=ADJ</i>		
<input type="checkbox"/>	L22	L21 not (ionic contaminants)	86
<input type="checkbox"/>	L21	L20 not (free adj2 particulate)	87
<input type="checkbox"/>	L20	L19 not (particulate free)	90
<input type="checkbox"/>	L19	(novolac or novolak) and L18	90
<input type="checkbox"/>	L18	(photoresist or (resist composition)) with (particulate or filler)	269
<input type="checkbox"/>	L17	particulate photoresist	2
	<i>DB=USPT,USOC,EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ</i>		
<input type="checkbox"/>	L16	particulate photoresist	9
<input type="checkbox"/>	L15	112 not L14	21
<input type="checkbox"/>	L14	insoluble particulates	1771
<input type="checkbox"/>	L13	('6632588' '6914714' '6458509' '6788452' '6545797')!.PN.	11
<input type="checkbox"/>	L12	17 not (18 or 110 or 111)	45
<input type="checkbox"/>	L11	ionic adj contaminants	739
<input type="checkbox"/>	L10	free adj2 particulate	4220
<input type="checkbox"/>	L9	free adj of adj particulate	0
<input type="checkbox"/>	L8	particulate adj1 free	1325
<input type="checkbox"/>	L7	L6 and 15	81
<input type="checkbox"/>	L6	novolac or novolak <i>el</i>	42270
<input type="checkbox"/>	L5	(photoresist or (resist adj composition)) with particulate	356
<input type="checkbox"/>	L4	12 and L3	0
<input type="checkbox"/>	L3	photoresist or (resist adj composition)	130079
<input type="checkbox"/>	L2	bismuth adj borate	57
<input type="checkbox"/>	L1	(bismuth or bismuth) adj1 borate adj1 frit <i>Spec.</i>	0

END OF SEARCH HISTORY

Searches for User *rashton* (Count = 1770)

Queries 1721 through 1770.

Find

S #	Updt	Database	Query	Time	Cor
<u>S1770</u>	<u>U</u>	USPT,USOC,EPAB,JPAB,DWPI	novolac or novolak and (photoresist or (resist adj composition)) with particulate	2005- 08-13 15:09:33	
<u>S1769</u>	<u>U</u>	USPT,USOC,EPAB,JPAB,DWPI	novolac or novolak	2005- 08-13 15:09:16	
<u>S1768</u>	<u>U</u>	USPT,USOC,EPAB,JPAB,DWPI	(photoresist or (resist adj composition)) with particulate	2005- 08-13 15:08:44	
<u>S1767</u>	<u>U</u>	USPT,USOC,EPAB,JPAB,DWPI	bismuth adj borate and photoresist or (resist adj composition)	2005- 08-13 15:08:16	
<u>S1766</u>	<u>U</u>	USPT,USOC,EPAB,JPAB,DWPI	photoresist or (resist adj composition)	2005- 08-13 15:08:00	
<u>S1765</u>	<u>U</u>	USPT,USOC,EPAB,JPAB,DWPI	bismuth adj borate	2005- 08-13 15:07:20	
<u>S1764</u>	<u>U</u>	USPT,USOC,EPAB,JPAB,DWPI	(bismuth or bismuth) adj1 borate adj1 frit	2005- 08-13 15:06:15	
<u>S1763</u>	<u>U</u>	USPT,USOC,EPAB,JPAB,DWPI	wo-9733198-\$.did.	2005- 08-08 11:44:54	
<u>S1762</u>	<u>U</u>	PGPB	431058.ap.	2005- 08-08 11:34:15	
<u>S1761</u>	<u>U</u>	PGPB	897122.ap.	2005- 08-08 11:26:08	
<u>S1760</u>	<u>U</u>	USPT,USOC,EPAB,JPAB,DWPI,TDBD	(siloxane or polysiloxane) with (light absorbing) and (siloxane or polysiloxane) with (lactone or amide or ether or nitrile or ester or	2005- 08-07 22:26:30	